surface science

Abstracted/indexed in: Aluminium Industry Abstracts; Chemical Abstracts; Current Contents; Physical, Chemical and Earth Sciences; EI Compendex Plus; Engineered Materials Abstracts; Engineering Index; INSPEC; Metals Abstracts; Physics Briefs.

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USA POSTMASTERS: Send address changes to Surface Science, Publications Expediting, Inc., 200 Meacham Avenue, Elmont, NY 11003. Airfreight and mailing in the USA by Publications Expediting.

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